#2/105 in Sulin 3/13/02

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Tomihide YASUMOTO

Serial Number: Not Yet Assigned

Filed: November 29, 2001

or: A SEMICONDUCTOR DEVICE MANUFACTURING METHOD USING

METAL SILICIDE REACTION AFTER ION IMPLANTATION IN

SILICON WIRING

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents Washington, D.C. 20231

November 29, 2001

Sir:

In compliance with 37 CFR 1.56, Applicant calls to the attention of the Patent and Trademark

Office the reference listed on the attached PTO-1449.

A copy of the reference is enclosed herewith.

In the event there are any fees due in connection with the filing of this paper, please charge Deposit Account No. <u>01-2340</u>.

Respectfully submitted,
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Enclosures: PTO-1449; Reference (1)